

Module Description, available in: EN

Applied Micro & Nano Technologies

General Information**Number of ECTS Credits**

3

Module code

TSM_AppMNT

Valid for academic year

2024-25

Last modification

2023-09-25

Coordinator of the module

Martin Gutsche (OST, martin.gutsche@ost.ch)

Explanations regarding the language definitions for each location:

- Instruction is given in the language defined below for each location/each time the module is held.
- Documentation is available in the languages defined below. Where documents are in several languages, the percentage distribution is shown (100% = all the documentation).
- The examination is available 100% in the languages shown for each location/each time it is held.

	Lausanne			Lugano	Zurich		
Instruction					X E 100%		
Documentation					X E 100%		
Examination					X E 100%		

Module Category

TSM Technical scientific module

Lessons

2 lecture periods and 1 tutorial period per week

Entry level competences**Prerequisites, previous knowledge**

Basic knowledge in chemistry and physics

Brief course description of module objectives and content

Based on selected examples, this module imparts the scientific and technological basics as well as the possibilities and the perspectives of the micro- and nanotechnologies to the participants. The students will become aware of the enormous potential of applications of this field and acquire a certain ability in handling it.

Aims, content, methods

Learning objectives and acquired competencies

- the students know the scientific and technological basics of this technology
- the students have a general understanding of the numerous fields of the micro- and nanotechnologies and their applications
- the students are able to combine the advantages of scaling and materials with the desired functions of the device
- based on selected nanodevices the students develop the ability to apply specific nano properties

Contents of module with emphasis on teaching content

Introduction to modern devcie fabrication

- scaling laws
- from photo- to nanolithography and self-assembly
- technologies for the deposition of materials and the structuring of surfaces with the intention to realize certain electrical and other properties
- nanotools for the analysis and the modification of surfaces
- surface topography on micro- and nanolevel: AFM, SEM/TEM, IOM, FIB

Future technologies

- from MEMS to NEMS
- fullerene-based nanosystems and functional nanocomposites
- biomedical applications of nanotechnology
- micro- and nanofluidics
- nanosafety and risks

Teaching and learning methods

Lectures and exercises

Literature

Assessment

Certification requirements

Module does not use certification requirements

Basic principle for exams

As a rule, all the standard final exams for modules and also all resit exams are to be in written form

Standard final exam for a module and written resit exam

Kind of exam

written

Duration of exam

120 minutes

Permissible aids

No aids permitted

Special case: Resit exam as oral exam

Kind of exam

oral

Duration of exam

30 minutes

Permissible aids

No aids permitted